SHIGA7.043APC PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

: Hayashi et al.

Appl. No.

10/565,696

Filed

: January 24, 2006

For:

RESIN FOR RESIST, POSITIVE RESIST COMPOSITION, AND METHOD OF FORMING RESIST

PATTERN

Examiner

Huhn, R.

Group Art Unit

4131

AMENDMENT AND RESPONSE TO OFFICE ACTION

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **September 22, 2008**, please amend the above-referenced application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 8 of this paper.